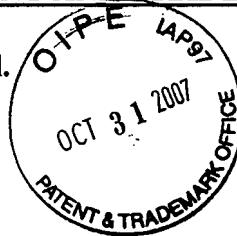


IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **Miwa KOZAWA et al.**

Application Number: **10/629,806**

Filed: **July 30, 2003**



Group Art Unit: **1795**

Examiner: **Sin J. Lee**

Confirmation Number: **9494**

For: **RESIST PATTERN THICKENING MATERIAL, PROCESS FOR
FORMING RESIST PATTERN, AND PROCESS FOR
MANUFACTURING SEMICONDUCTOR DEVICE**

Attorney Docket Number: **030923**

Customer Number: **38834**

AMENDMENT TRANSMITTAL

Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

October 31, 2007

Sir:

Transmitted herewith is an Amendment in the above-identified application. The fee has been calculated as shown below.

	CLAIMS REMAINING AFTER AMENDMENT		HIGHEST NUMBER PREVIOUSLY PAID FOR	PRESENT EXTRA
Total (37 CFR 1.16(c))	24	Minus	21	= 3
Independent (37 CFR 1.16(b))	11	Minus	6	= 5
FIRST PRESENTATION OF MULTIPLE DEPENDENT CLAIM (37 CFR 1.16(d))				

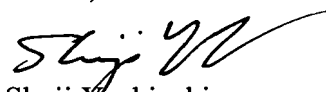
SMALL ENTITY		OR	OTHER THAN SMALL ENTITY	
RATE	ADDI- TIONAL FEE		RATE	ADDI- TIONAL FEE
X \$25		OR	X\$50	150.00
X \$105		OR	X\$210	1,050.00
+ \$185		OR	+ \$370	.00
TOTAL ADD'L FEE			TOTAL ADD'L FEE	1,200.00

XX Enclosed please find our check in the amount of **\$2,010.00** to cover the cost of the additional claims (\$1,200.00) and the Request for Continued Examination (\$810.00) in connection with this Amendment.

XX The Commissioner is hereby authorized to charge payment for any additional fees associated with this communication or credit any overpayment to Deposit Account No. 50-2866.

Respectfully submitted,

WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP


Shuji Yoshizaki

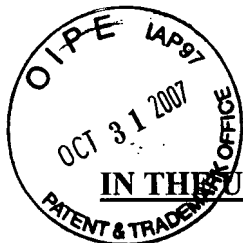
Limited Recognition

Registration No. L0111

Telephone: (202) 822-1100

Facsimile: (202) 822-1111

SY/mt



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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SUBMISSION UNDER 37 C.F.R. §1.114

Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

October 31, 2007

Sir:

This Submission is being filed concurrently with a Request for Continued Examination pursuant to 37 C.F.R. §1.114.

Amendments to the Claims begin on page 2 of this paper.

Remarks begin on page 17 of this paper.